AMENDMENTS TO THE CLAIMS

The following listing of claims replaces all prior listings, and all prior versions, of claims in the application.

LISTING OF CLAIMS:

1. (Original) A circuit board producing method in executing, inside a processing chamber, a treatment of forming a thin-film on a to-be-processed target or a treatment of processing said thin-film formed on said to-be-processed target, comprising the steps of:

performing an irradiation with a laser light into said processing chamber through an observing window, said laser light having a desired polarization and a desired wavelength and being intensity-modulated with a desired frequency,

wavelength-separating and light-receiving a light of a wavelength component of said frequency out of backward scattered-lights that have been scattered by particles inside said processing chamber through said irradiation and that have passed through said observing window,

detecting said frequency component out of said light-received signal obtained by being light-received,

obtaining, using said detected signal, information about number and size of said particles existing in a region irradiated with said laser light inside said processing chamber, and

outputting said obtained information about said number and said size of said particles.

2. (Original) The circuit board producing method as claimed in Claim 1, further comprising the steps of:

wavelength-separating, light-receiving, and image-photographing said light of said wavelength component out of said backward scattered-lights that have been scattered by said particles inside said processing chamber and that have passed through said observing window,

detecting said frequency component out of said light-received signal obtained by being light-received, and

judging at least one of said number, said size, and distribution of said particles by using said detected signal obtained by being detected and said image obtained by being image-photographed.

- 3. (Original) The circuit board producing method as claimed in Claim 1, wherein said desired polarization of said laser light is P-polarized state, an irradiation with said P-polarized laser beam being performed into said processing chamber through said observing window that is inclined in such a manner as to form Brewster angle toward said P-polarized laser beam.
- 4. (Original) The circuit board producing method as claimed in Claim 1, wherein a 2-dimensional distribution of said particles is judged by executing a rotation scanning of said irradiating beam in a horizontal direction, said irradiation with said irradiating beam being performed into said processing chamber through said observing window.

- 5. (Original) The circuit board producing method as claimed in Claim 1, wherein said desired frequency differs from a frequency of an exciting source and its integermultiples, said exciting source being used for said thin-film forming treatment or said thin-film processing treatment.
- 6. (Original) A circuit board producing method, comprising the steps of: applying a high-frequency voltage to electrodes inside a processing chamber in a state where a to-be-processed target has been transferred into said processing chamber, and generating plasma inside said processing chamber so as to process

introducing a laser light into said processing chamber through an observing window so as to irradiate, with said laser light, a region directly over said to-be-processed target that is being processed by said plasma, said laser light being intensity-modulated with a desired frequency,

said to-be-processed target,

detecting scattered-lights that have been scattered by particles inside said processing chamber through said irradiation and that have passed through said observing window,

obtaining, from said detected scattered-lights, information about said particles existing in said region directly over said to-be-processed target, said region having been irradiated with said laser light, and

outputting said obtained information about said particles.

- 7. (Original) The circuit board producing method as claimed in Claim 6, wherein, from said scattered-lights that have passed through said observing window, a light of a wavelength component of said desired frequency is wavelength-separated and detected through a filter.
- 8. (Original) The circuit board producing method as claimed in Claim 6, further comprising a step of obtaining, from said detected scattered-lights, information about size and distribution of said particles existing in said region directly over said to-be-processed target.
- (Original) A circuit board producing method, comprising the steps of: generating plasma inside a processing chamber so as to process a to-beprocessed target set inside said processing chamber,

introducing, in a middle of processing said to-be-processed target, a laser light into said processing chamber through an observing window so as to irradiate, with said laser light, a region directly over said to-be-processed target that is being processed by said plasma,

detecting scattered-lights in such a manner as to be separated from an emitted-light emitted from said plasma, said scattered-lights having been scattered by particles inside said processing chamber through said irradiation and having passed through said observing window,

determining, from said detected scattered-lights, information about size and distribution of at least said particles existing in said region directly over said to-be-processed target, and

Docket No. 500.39771X00 Serial No.09/763,735 Office Action dated June 1, 2007

displaying, on a monitor screen, said deter mined information about said size and said distribution of said particles existing in said region directly over said to-be-processed target.

- 10. (Original) The circuit board producing method as claimed in Claim 9, wherein said scattered-lights are detected in such a manner as to be separated from a reflected-light reflected from a wall surface of said processing chamber, said scattered-lights having been scattered through said irradiation by said particles floating inside said processing chamber.
- 11. (Original) The circuit board producing method as claimed in Claim 9, wherein, while monitoring a contamination situation inside said processing chamber in accordance with said information about said size and said distribution of said particles, a treatment of forming a thin-film on said to-be-processed target or a treatment of processing said thin-film formed on said to-be-processed target is executed inside said process¬ing chamber.
- 12 25. (Cancelled).